

Japan Patent Office online services

for Cooperating
Partners and Public



September 10, 2018

Information Technology Policy Planning Office

Table of Contents



1. Outline of JPO Systems

2. One Portal Dossier Service

(Cooperating Partner)

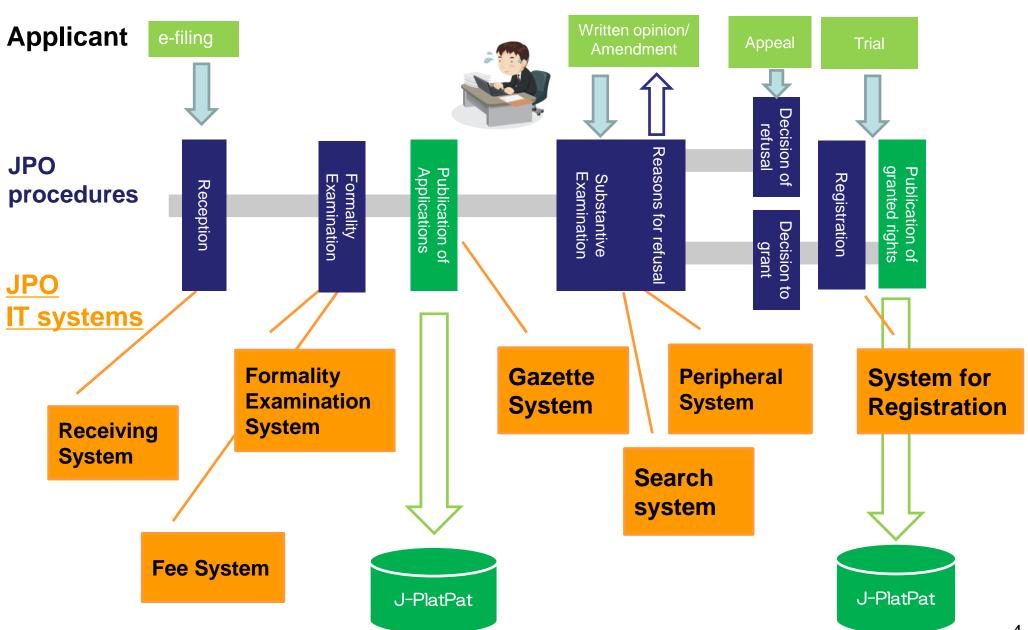
3. J-Plat pat service

(Cooperating Public)



- Receiving and Dispatch System
- Formality Examination and Fee System
- Gazette Editing System
- Public Dissemination
- Search System and Peripheral System





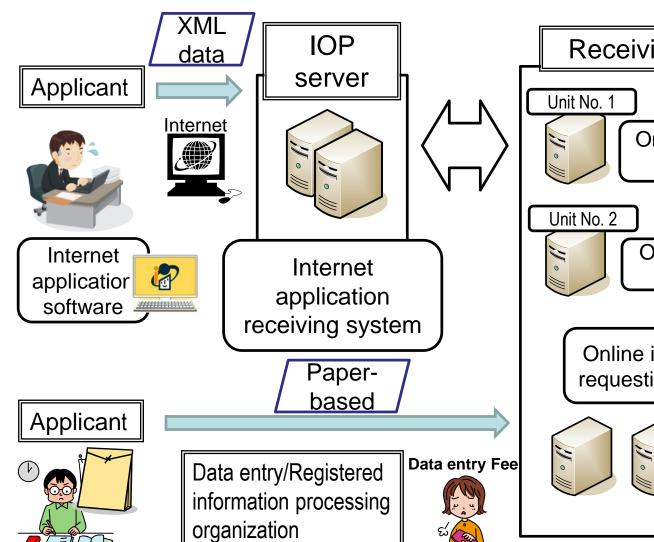


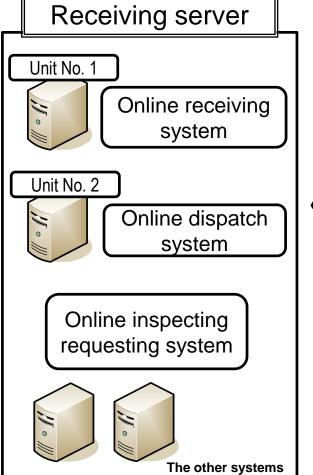
- Receiving and Dispatch System
- Formality Examination and Fee System
- Gazette Editing System
- Public Dissemination
- Search System and Peripheral System

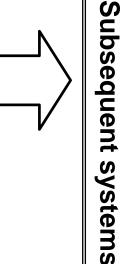
Online receiving system



IOP server and receiving server





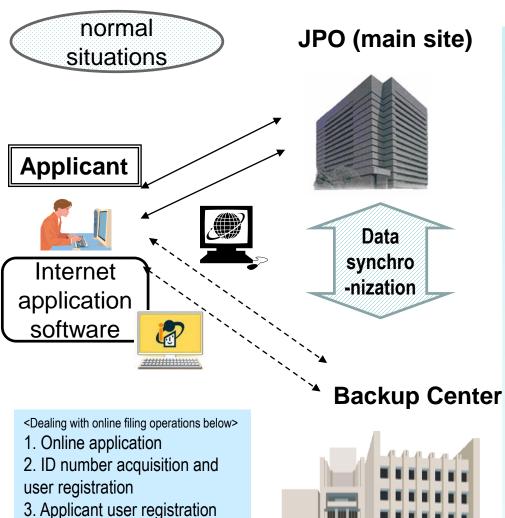


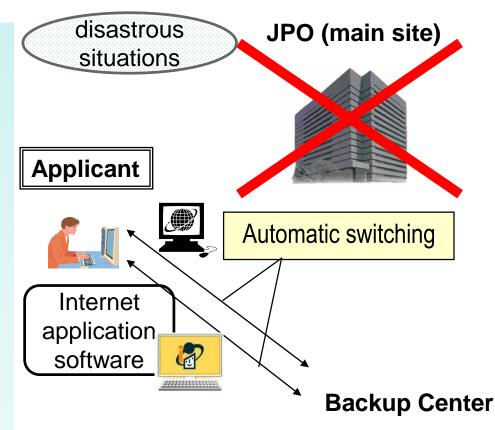
Backup Center

4. Electronic certificate addition

5. Application history information inquiry



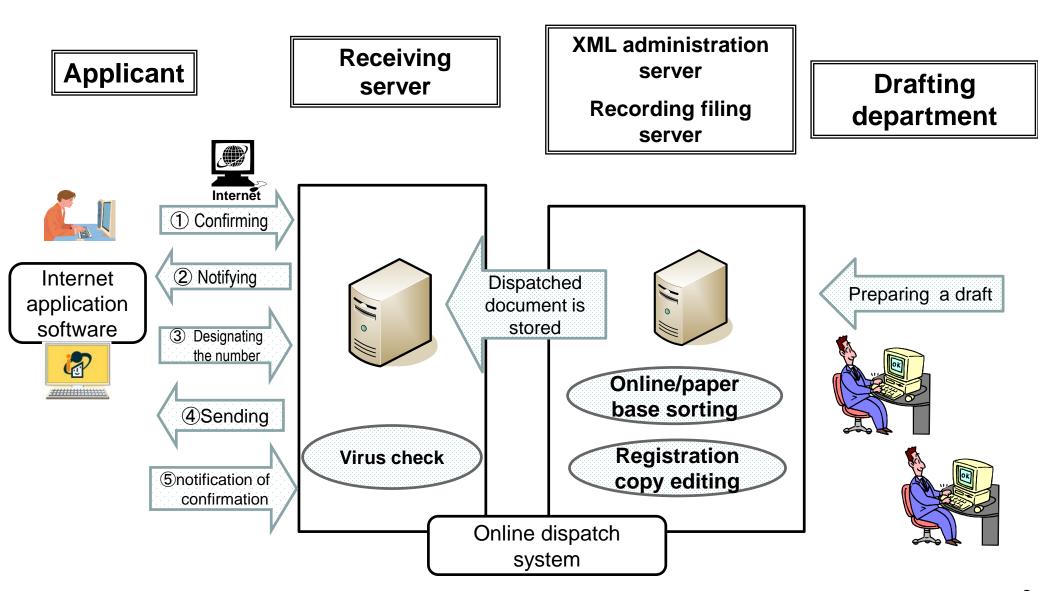






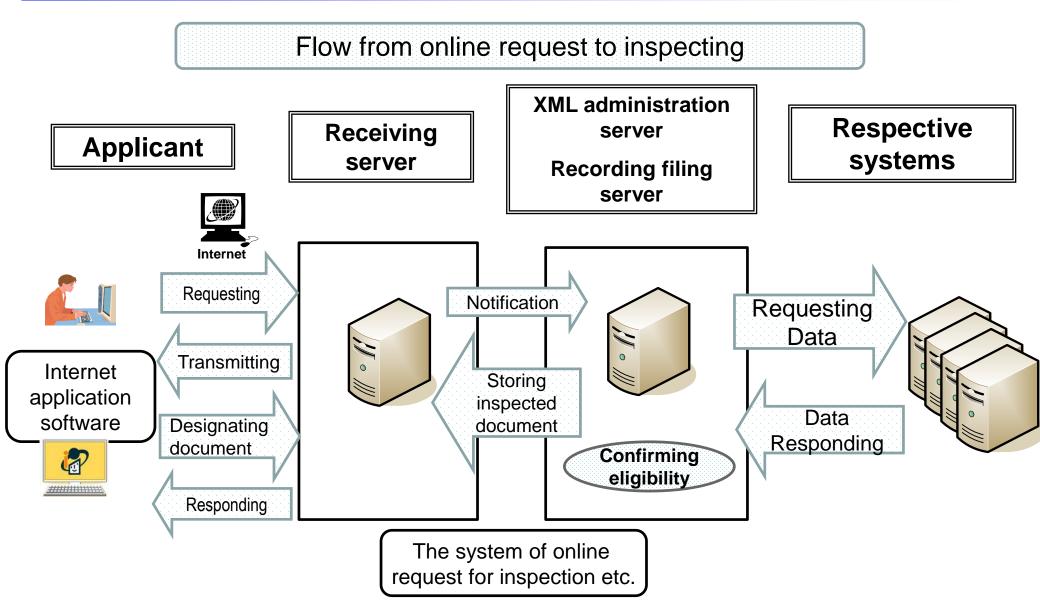
Online dispatch system





Online request for inspection





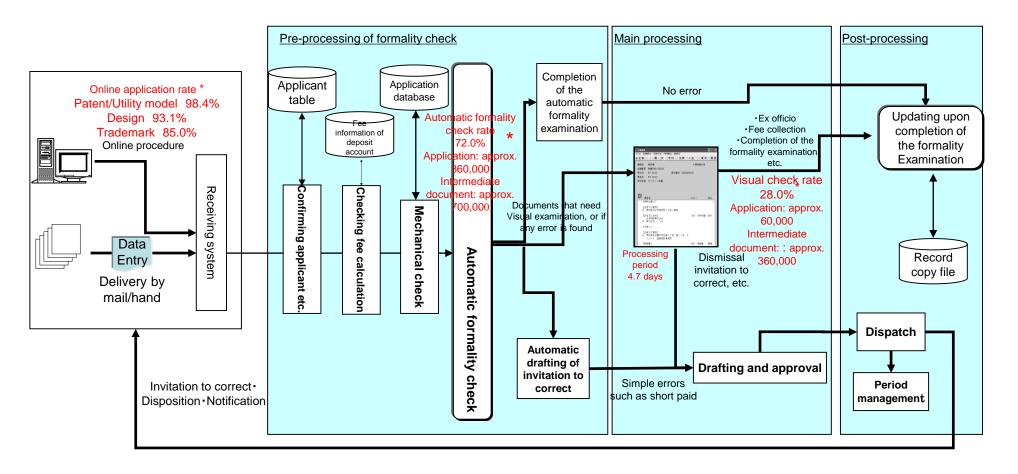


- Receiving and Dispatch System
- Formality Examination and Fee System
- Gazette Editing System
- Public Dissemination
- Search System and Peripheral System

Overview of Formality Examination System



*As these are figures at the time of machine processing, they are different from those in the annual statistic

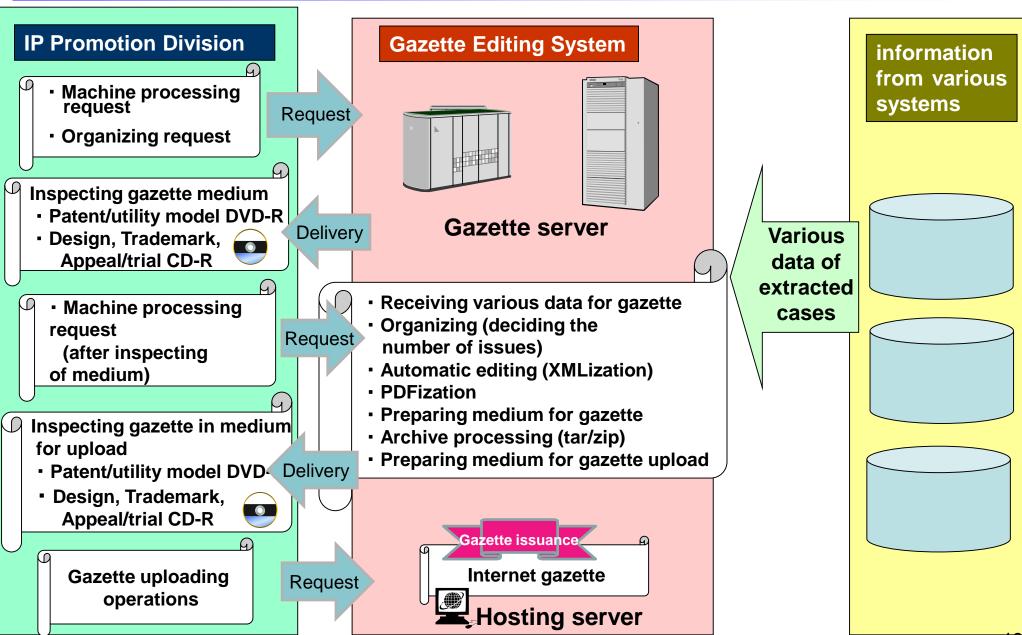




- Receiving and Dispatch System
- Formality Examination and Fee System
- Gazette Editing System
- Public Dissemination
- Search System and Peripheral System

Gazette Editing System job image (outline)



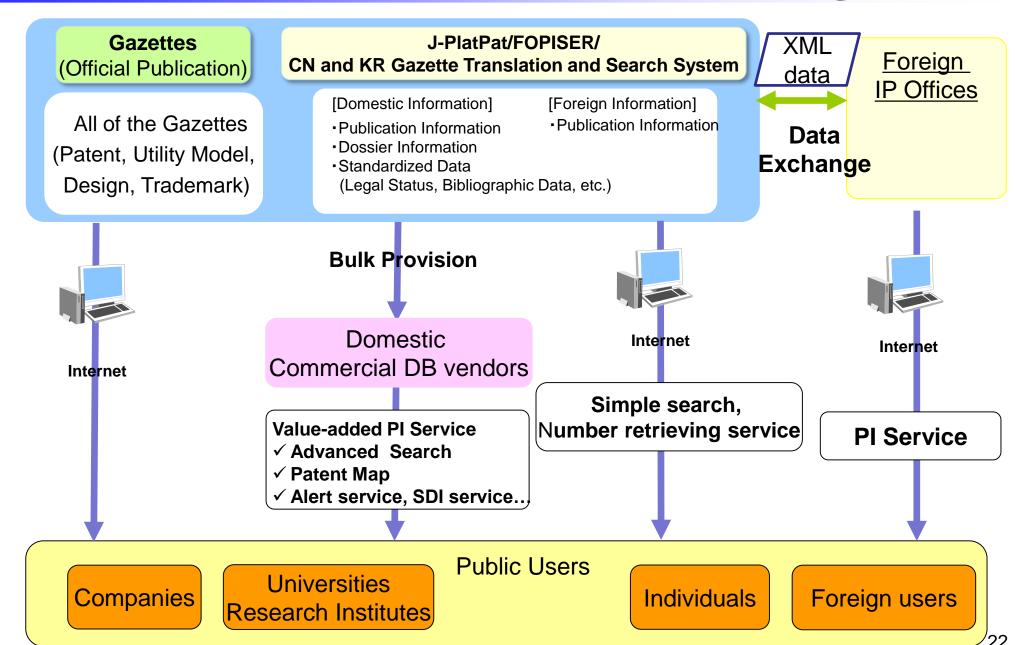




- Receiving and Dispatch System
- Formality Examination and Fee System
- Gazette Editing System
- Public Dissemination
- Search System and Peripheral System

Framework of Public Dissemination of Data



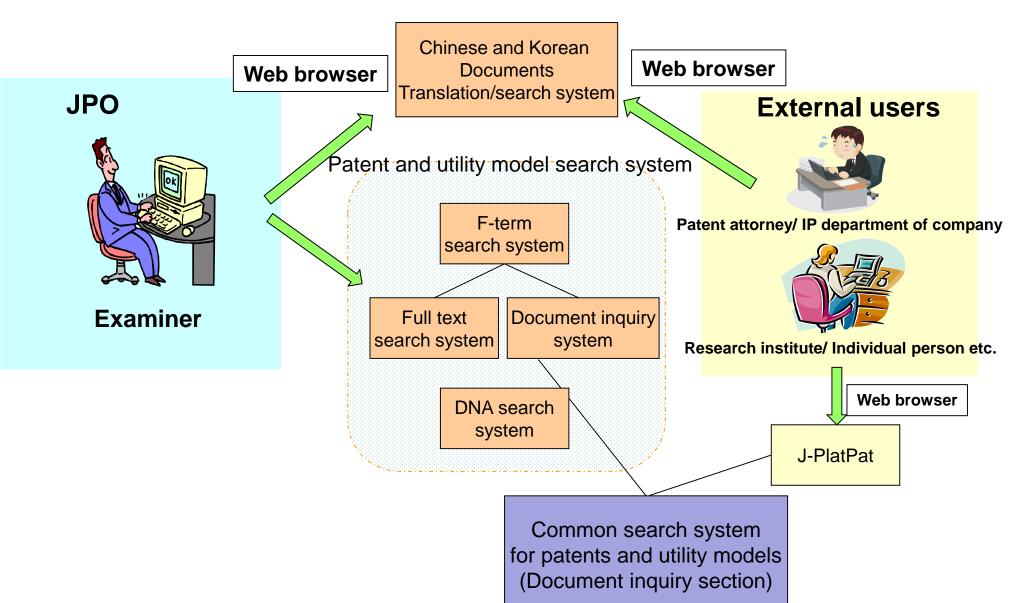




- Receiving and Dispatch System
- Formality Examination and Fee System
- Gazette Editing System
- Public Dissemination
- Search System and Peripheral System

Overview of patent & utility model search system





Conclusion of the Outline of JPO Systems



By computerization of documents

- ✓ A great number of applications can be processed at each phase
- ✓ Users can use various services on the web which the office provides

And more

- ✓ For processing a great number of applications efficiently
- ✓ For reducing the work of applicants and improving the convenience
- ✓ For exchanging data to the other offices



XMLization of documents about imcoming/outgoing is important

Table of Contents



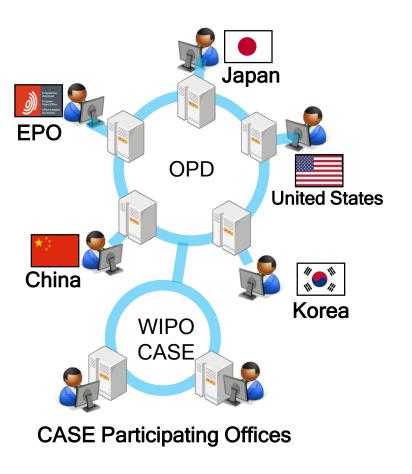
2. One Portal Dossier Service

Japanese Patent Process Flow: Detail of Search



<u>Utilization of Foreign Dossier Information</u>

- ✓ JPO examiners retrieve foreign dossier information via One Portal Dossier (OPD).
- ✓ Workload of examination is reduced.
- ✓ Quality of examination can be improved by utilizing foreign Dossier Information.





Global Dossier: Linkage to JPO's internal systems



- > JPO has developed linkage between internal systems and the OPD.
- Usability for JPO's examiners is significantly improved.





Search and View System



Application Management System (List of Applications)

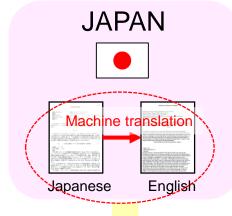


Examination Assistance System

Actions for Work Sharing and International Cooperation



Provision of JPO's search/examination results (Dossier Information)



69 IPOs around the world can refer to JPO's dossier information via AIPN.

JPO exchanges its dossier information with IP5 Offices via One Portal Dossier System.

WIPO-CASE participants can refer to IP5 Offices' dossier information via WIPO-CASE in addition to that of AU, CA, GB, IL, IN, NZ and WO.

One Portal Dossier

IP5's Dossier sharing system



Europäisches Patentamt European Patent Office Office européen des brevets

United States

EPO

★: China Korea

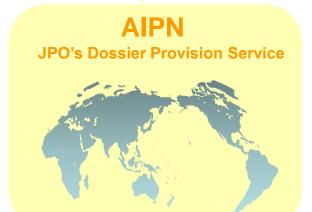
Linkage

WIPO-CASE

WIPO's Dossier sharing system

In addition to IP5, 27 countries/organizations as of April 2018.

**Participating offices excluding IP5 Offices: AU, AZ, BN, KH, CA, CL, CR, EG, GB, IN, ID, IL, LA, MY, MN, NZ, PG, PH, PT, SG, TH, VN, PE, UA, GE, EAPO, WIPO



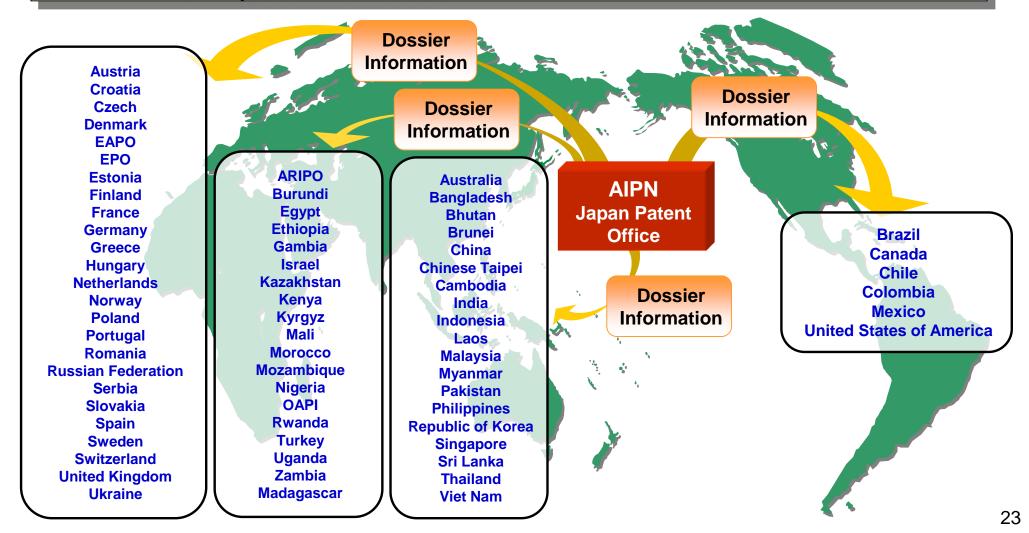
Merits for Dossier Information sharing

- (1) Reduce workload in examination at IPOs
- (2) Give IP rights quickly and properly

Advanced Industrial Property Network (AIPN)



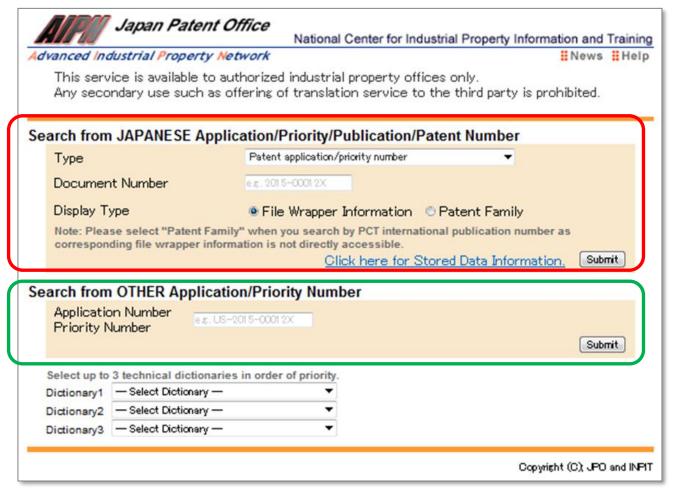
- ✓ AIPN is a dossier information sharing system developed by the JPO.
- ✓ AIPN has offered its service since October 2004
- ✓ AIPN is used by 69 IP Offices around the world in 2018.



Advanced Industrial Property Network (AIPN)



User Interface of the AIPN URL:https://aipn.j-platpat.inpit.go.jp/AI2/cgi-bin/AIPNSEARCH



Search with JP document number such as,

- Application number,
- Priority Number,
- Publication Number, or
- Patent Number.

Search with Other country's document number such as,

- Application number, or
- Priority Number.

Conclusion of One Portal Dossier Service



- JPO provides the examination information for many offices by using the OPD, WIPO-CASE, and AIPN service.
 - ✓ For reducing the redundant search and improving the efficiency by providing them
 - ✓ JPO expects a lot of countries will participate the WIPO-CASE as the providing office

- The interface of the JPO-OPD system is devised in detail
 - ✓ For improving the convenience for users

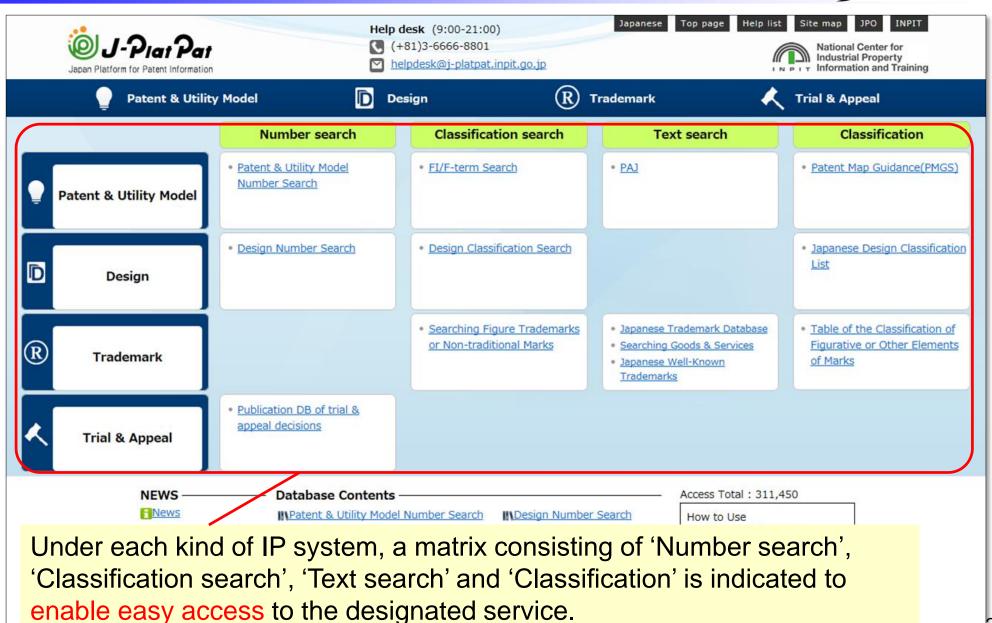
Table of Contents



3. J-Plat Pat Service

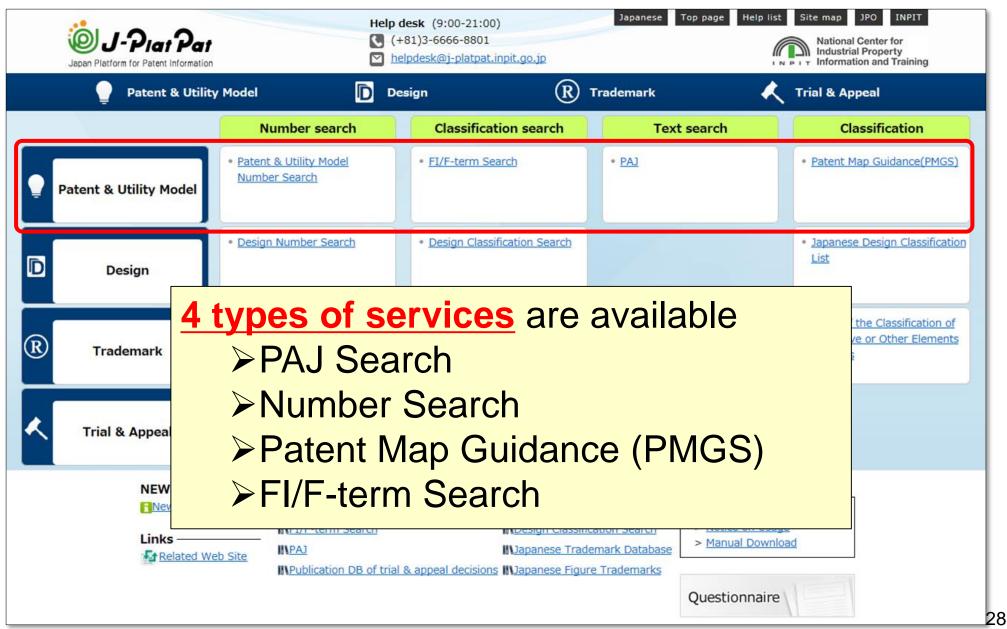
Overview of the J-PlatPat





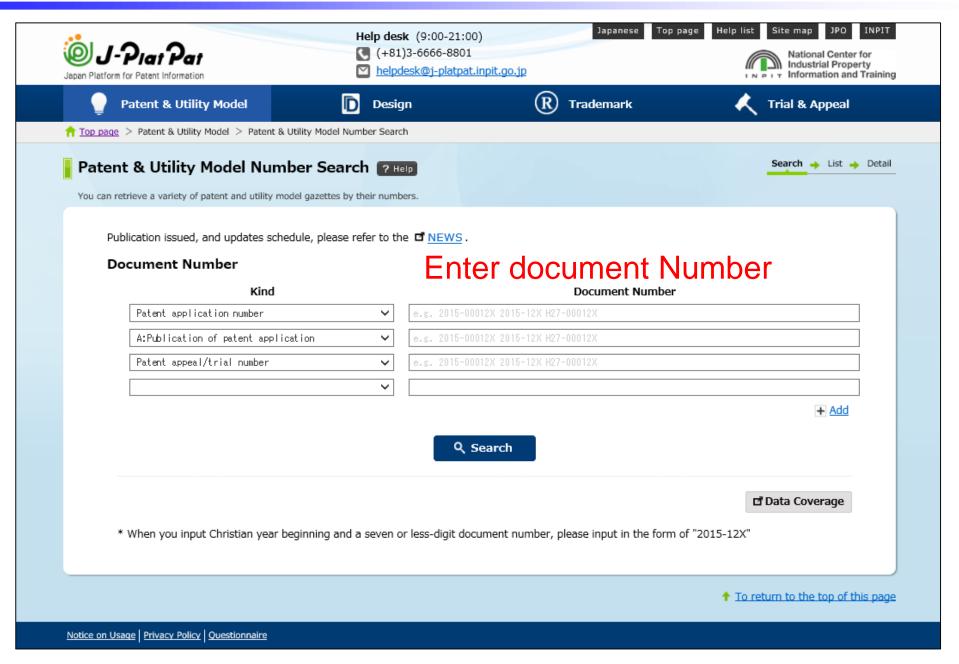
Overview of the J-PlatPat





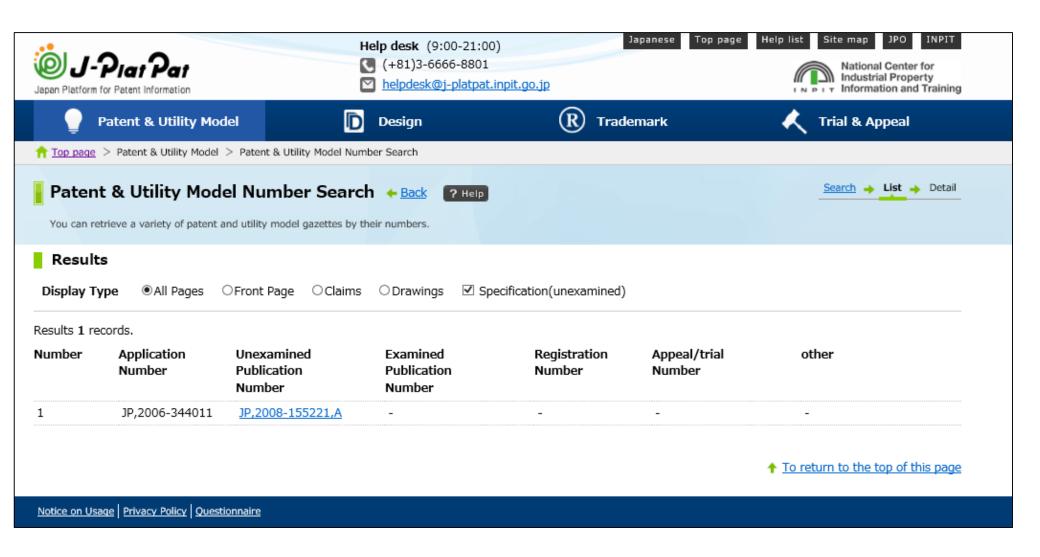
How to Retrieve JP Publications at J-PlatPat





How to Retrieve JP Publications at J-PlatPat

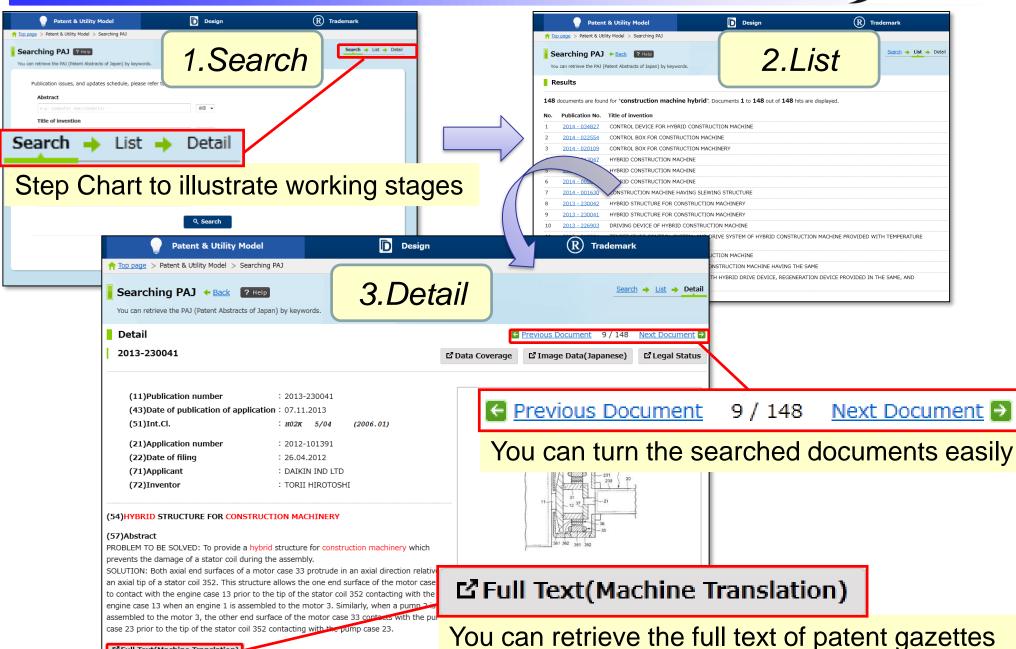




PAJ Search

☐ Full Text(Machine Translation)

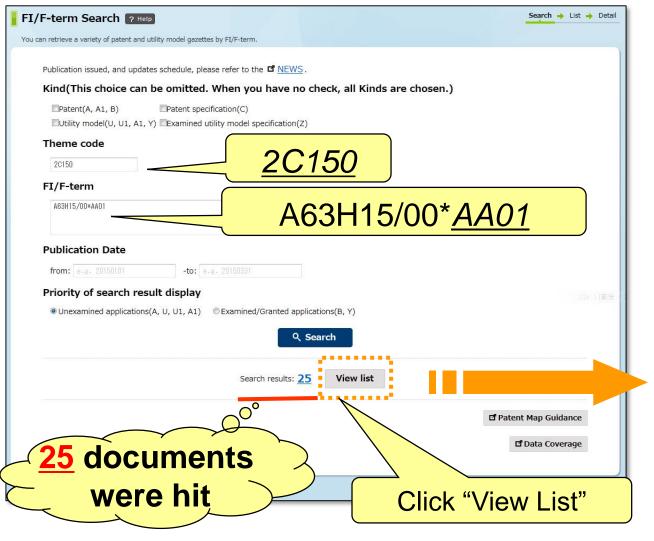


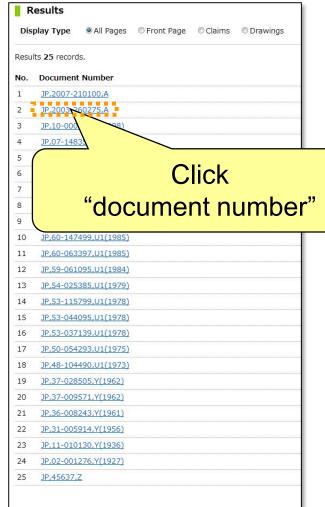


FI/F-term Search



F-term: 2C150 AA01 AND FI: A63H15/00 (example)





Global Dossier: Public Access Service



- Dossier information is available both in original language and in machinetranslated English at one stop.
- Data coverage of Japanese OPD public service is enriched, i.e. IP5 Offices, Australia, Canada, and the PCT
- Currently, Japanese interface only; English interface is to be developed.



Advantages!

- Access to the latest information!
- Being able to compare the examination results among several offices all at once!
- Direct access to document contents!

[JP Dossier]

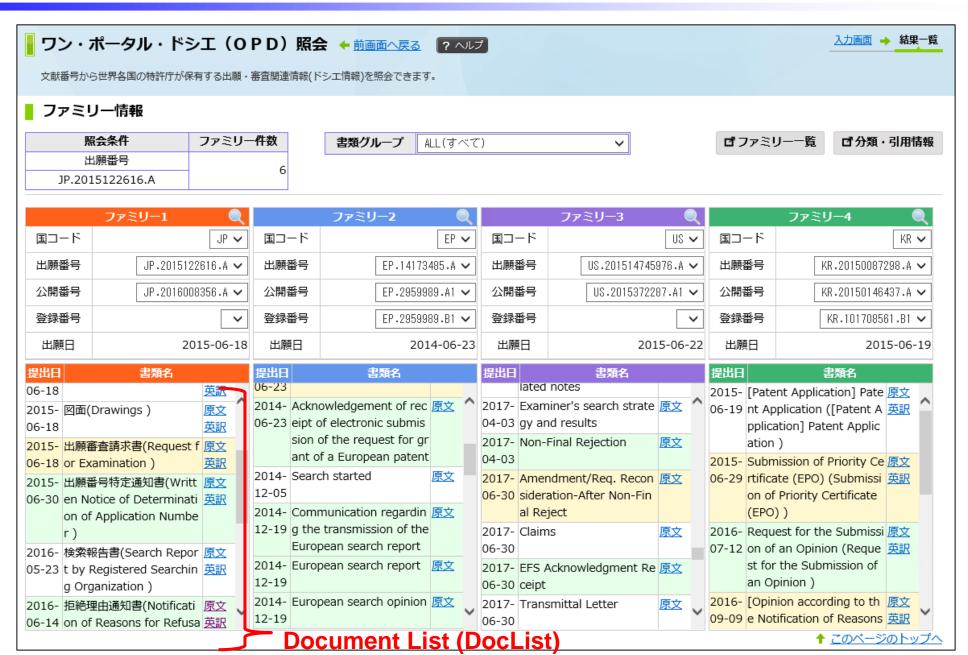
EP Dossier

(US Dossier)

(Others)

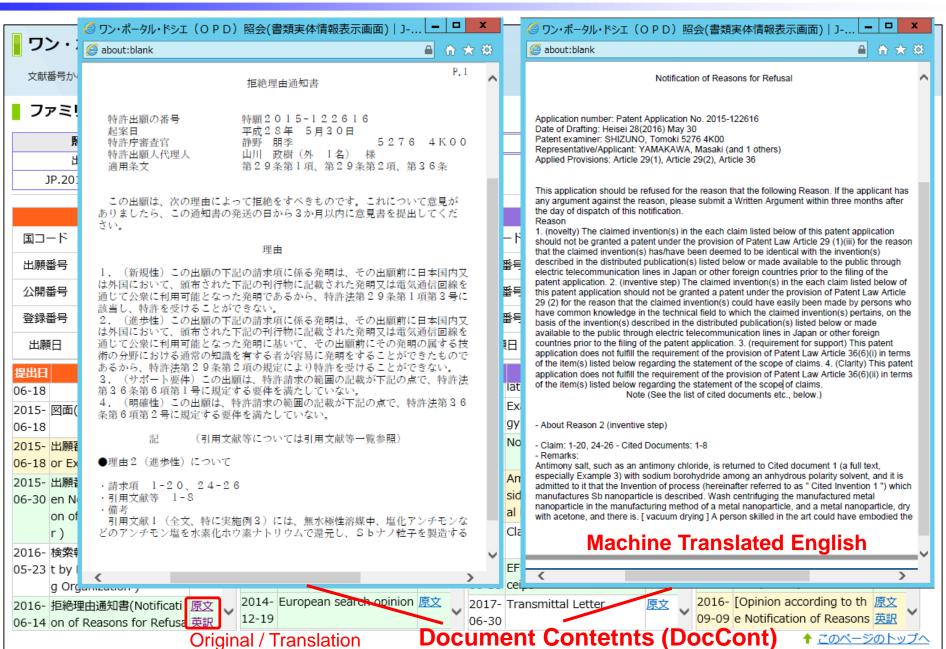
Current Service (JPO providing for Public users)





Current Service (JPO providing for Public users)





Current Service (JPO providing for Public users)





Enriched Citation Data



- ✓ JPO started the entry of "Enriched Citation Data" by examiners in March 2017. *Old applications are not related to "Enriched Citation Data"
- ✓ Category, Claims and Related Passages are displayed with the cited document number on OPD & WIPO-CASE.



You can easily identify important documents! (X or Y documents)

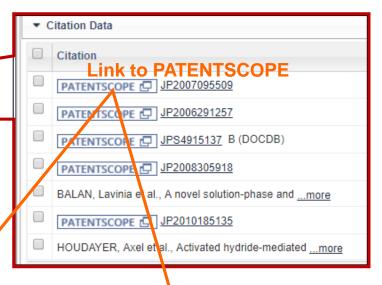
項番	カテゴリ	引用文献番号	形式	公知日	引用箇所	請求項		
1	Х	JP.2012138333.	docdb		Paragraphs0023,0045-0050, Figures1,	1, 5	П	
	Υ	Α			8-10	2 – 4	Н	
					Paragraphs0023,0045-0050, Figures1,		П	
					8-10		▎▐	You can easily understand
2	Υ	JP.2013033710.	docdb		Paragraphs0039-0042, Figures2-4,8-9	2 – 4	П	these documents are related to
		Α						"Novelty" or "Inventive Step".
3		JP.2012138333.	docdb					restriction of involute clop:
		Α						
4		JP.2013033710.	docdb				П	
		Α						These documents are not related to
5		JP.2012227004.	docdb					"Novelty" and "Inventive Step".
		Α						

Access to JP Publications from WIPO CASE



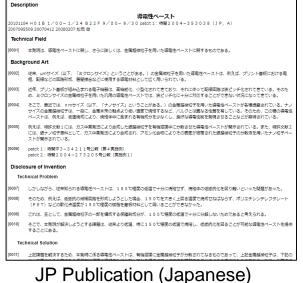
WIPO CASE





PATENTSCOPE



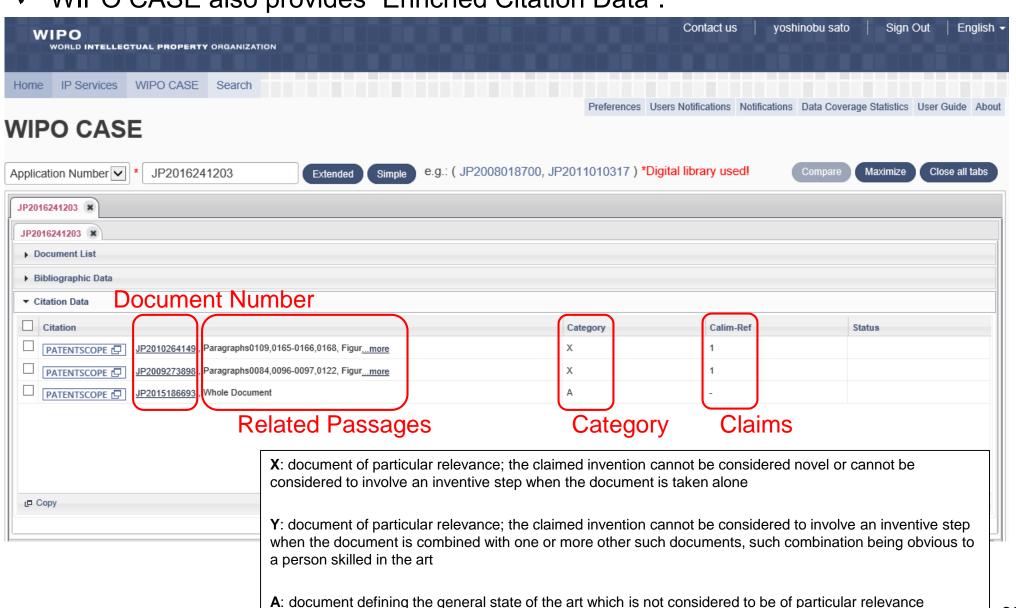


Description 0101104 H01b (1) # hog / 00-1 # / 24 b22f9 / 00-9 # / 30 patt1; japanese patent application laid-open no. 2004-353038 (JP, a) **Wipo Transl** 007095509 20070412 20080207 Matsuoka [Continue Technical Field The present invention relates to conductive pastes, and more particularly to conductive pastes, the present invention relates to a conusing metal ultrafine particles Conventionally, a micrometer size (hereinafter referred to as "micron size") is known. In the conductive paste using the metal fine particles of the present invention, for example, an electrode, a wiring, or the like on a printed circuit board is formed, and is widely used as a conductive material for In recent years, an electronic apparatus into which a printed circuit board is incorporated has been highly functionalized and miniaturized, along with this, the wiring circuit has been narrowed to a narrow pitch. Thus, a general-purpose conductive paste using micron-sized metal particulates is used Therefore, recently, the nm size (hereinafter referred to as "nano size") is known. A conductive paste using the metal ultrafine particles of the present invention has been proposed. Nano-sized metal ultrafine particles are generally used, and has a property different from that of the bulk, such as sintering at a temperature lower than the melting point of the metal. The conductive paste of this type is, for example, the organic component contained in the sintered body is reduced by low-temperature baking, and it is expected that a good conductive performance is exhibited For example, patent document 1, and the silver uttrafine particles synthesized by the gas evaporation method are dispersed in an organic solvent Also, patent documents (2) is synthesized by a gas evaporation method as a silver nanoparticle raw material, a nanoparticle paste using a dispersion of silver ultrafine particles coated with the surface thereof by an amine compound is disclosed Patt1: japanese patent application laid-open no. 3-34211 (fourth embodiment) PatCI2: japanese patent application laid-open no. 2004-273205 (example 1) Disclosure of Invention Technical Droblem nal conductive paste is not sufficiently sintered at a low temperature of about 150° c, it is difficult to reduce the Therefore, for example, when a fine circuit having a low resistance is to be formed, at a temperature higher than 150° c; polyethylene terephthalate (PET), a resin having a softening point temperature of about 150°c or the like cannot be used as a substrate materia This is mainly a protective agent component constituting a part of the metal ultrafine particles, it is considered that it is not sufficiently decomp

"Enriched Citation Data" in Citation Data of WIPO CASE



✓ WIPO CASE also provides "Enriched Citation Data".



Conclusion of J-Plat Pat service



- Convenient Information for users is provided by J-Plat Pat service
- Information of the other offices is provided by using OPD and WIPO-CASE
- Information is utilized by the users' of other countries beside the users of Japan

And more

 It is scheduled that reforming the interface and increasing the amount of data in 2019.



✓ <u>Computerization and XMLization</u> of documents about imcoming/outgoing is important

2. One Portal Dossier Service

✓ Importance of mutual using of the examination information through the OPD, WIPO-CASE, and AIPN service

3. J-Plat pat service

✓ Importance of providing the information which the JPO has to users for utilizing efficiently



Thank you